

Overview of plasma technology for accelerators

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Plasma technologies can be used to design several types of accelerator components



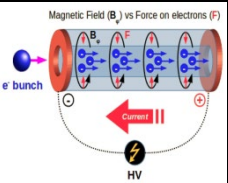
Source of electrons:

Driven by laser wakefields in plasmas cells or jets

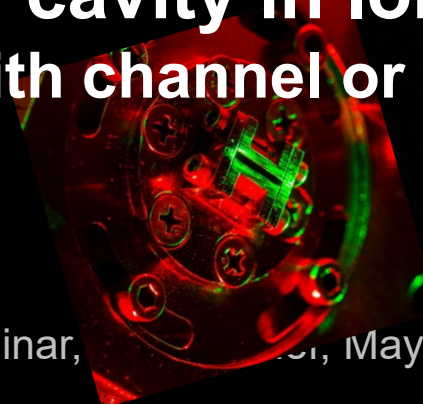
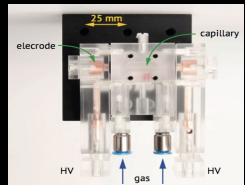


Electron lens:

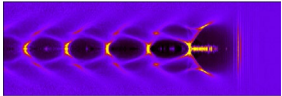
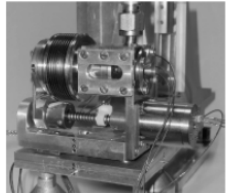
Focusing force associated to azimuthal magnetic field in discharge plasma



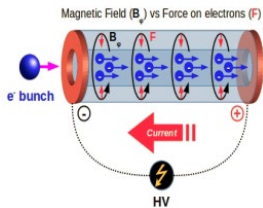
Accelerating cavity in long plasmas: waveguides with channel or homogeneous plasma



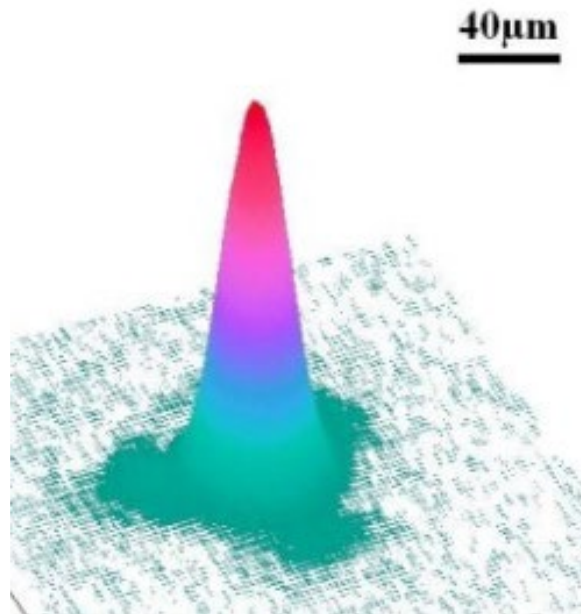
Outline



- Plasmas for laser driven compact sources of electrons in non Linear regimes
- Plasma based accelerator cavity: for laser or beam driven wakefield accelerators
- Plasmas for beam optics



Driving laser amplitude characterized by a normalized parameter



- ➡ Laser strength parameter

$$a \sim eA/mc^2$$

normalized laser vector potential

- ➡ Peak value

$$a_0 \sim 8.5 \times 10^{-10} \lambda_0 [\mu\text{m}] I_0^{1/2} [\text{Wcm}^{-2}]$$

- ➡ Quasilinear regime or weakly relativistic regime

$$a_0 \sim 1$$

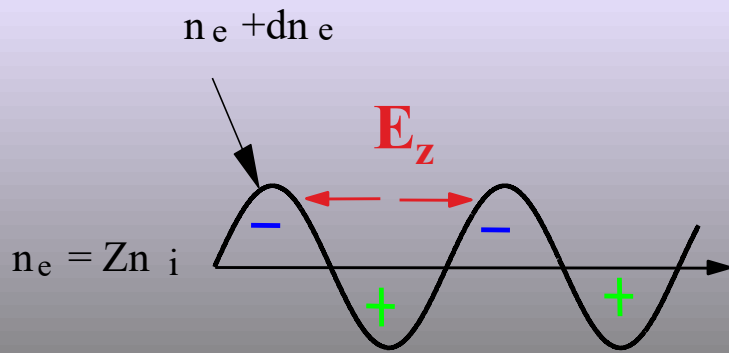
Large longitudinal electric field associated to a plasma wave



Accelerating fields > 10 GV/m for LWFA

➡ Space charge field and plasma wave wavelength

$$\lambda_p[\mu\text{m}] \sim 33 (n_e[10^{18}\text{cm}^{-3}])^{-1/2}$$



$$E_z [\text{GV/m}] \sim 96 (n_e [10^{18} \text{cm}^{-3}])^{1/2} dn_e/n_e$$

$$E_z [\text{GV/m}] = 1.35 \cdot 10^{-18} I_{\text{max}} [\text{Wcm}^{-2}] (\lambda [\mu\text{m}])^2 / \tau [\text{ps}]$$

LWFA density regimes



► Energy gain in LWFA

Linear Regime ($a_0 \simeq 1$):

$$W_{\max} = 2a_0^2 \gamma_{\text{ph}}^2 mc^2 \approx a_0^2 (n_{\text{cr}}/n_e) \text{ MeV}$$

Non-linear Regime ($a_0 \gtrsim 2$):

$$W_{\max} = \frac{2}{3} a_0 \gamma_{\text{ph}}^2 mc^2 \approx \frac{1}{3} a_0 (n_{\text{cr}}/n_e) \text{ MeV}$$

► Sets roughly plasma density

For 1 GeV gain: $n_e \approx 10^{-3} n_{\text{cr}} \approx 2 \times 10^{18} \text{ cm}^{-3}$

For 4 GeV gain: $n_e \approx 2.5 \times 10^{-4} n_{\text{cr}} \approx 5 \times 10^{17} \text{ cm}^{-3}$



LWFA interaction lengths



$$L_{\text{dp}} \approx \gamma_{\text{ph}}^2 \lambda_p \approx (n_{\text{cr}}/n_e)^{3/2} \lambda_0$$

► Dephasing length

For 1 GeV gain: $(n_{\text{cr}}/n_e) \approx 1000$, $L_{\text{dp}} \approx 3 \text{ cm}$

For 4 GeV gain: $(n_{\text{cr}}/n_e) \approx 4000$, $L_{\text{dp}} \approx 25 \text{ cm}$

► For a spot size
 $w_0 \approx \lambda_p = \left(\frac{2\pi c}{\omega_p} \right) \approx 30(60) \mu\text{m}$ for 1(4) GeV

Rayleigh range: $z_R \approx \pi w_0^2 / \lambda_0 \approx 3(12) \text{ mm}$

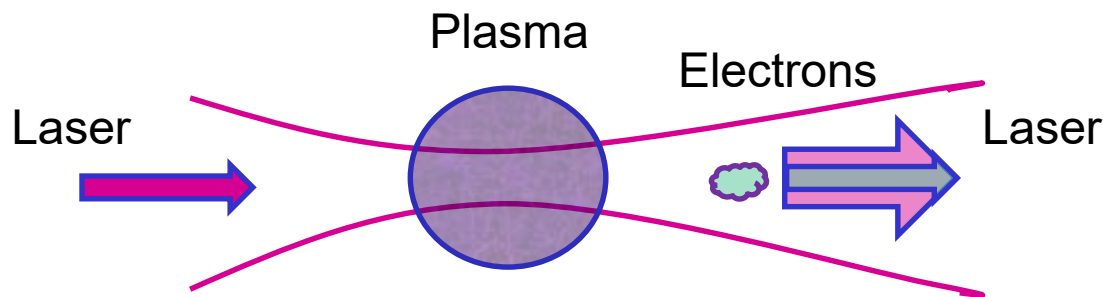
Need guiding over 10 (20) z_R



Plasma based electron sources rely on NL laser wakefield acceleration



- Non linear interaction of an intense laser with gas responsible for gas ionisation, electron acceleration



Intense laser

creates a plasma

drives plasma waves,

traps plasma electrons

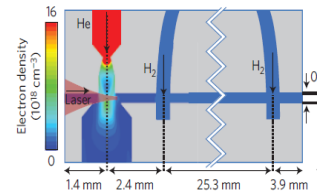
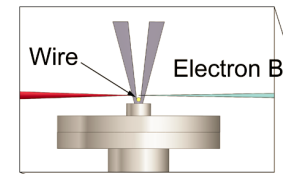
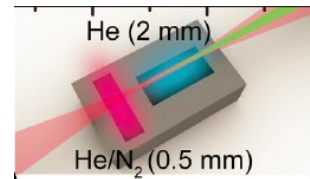
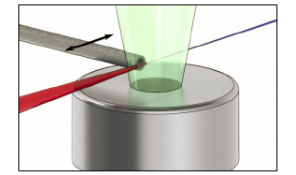
accelerate electrons

$I > I_{\text{ionization}}$

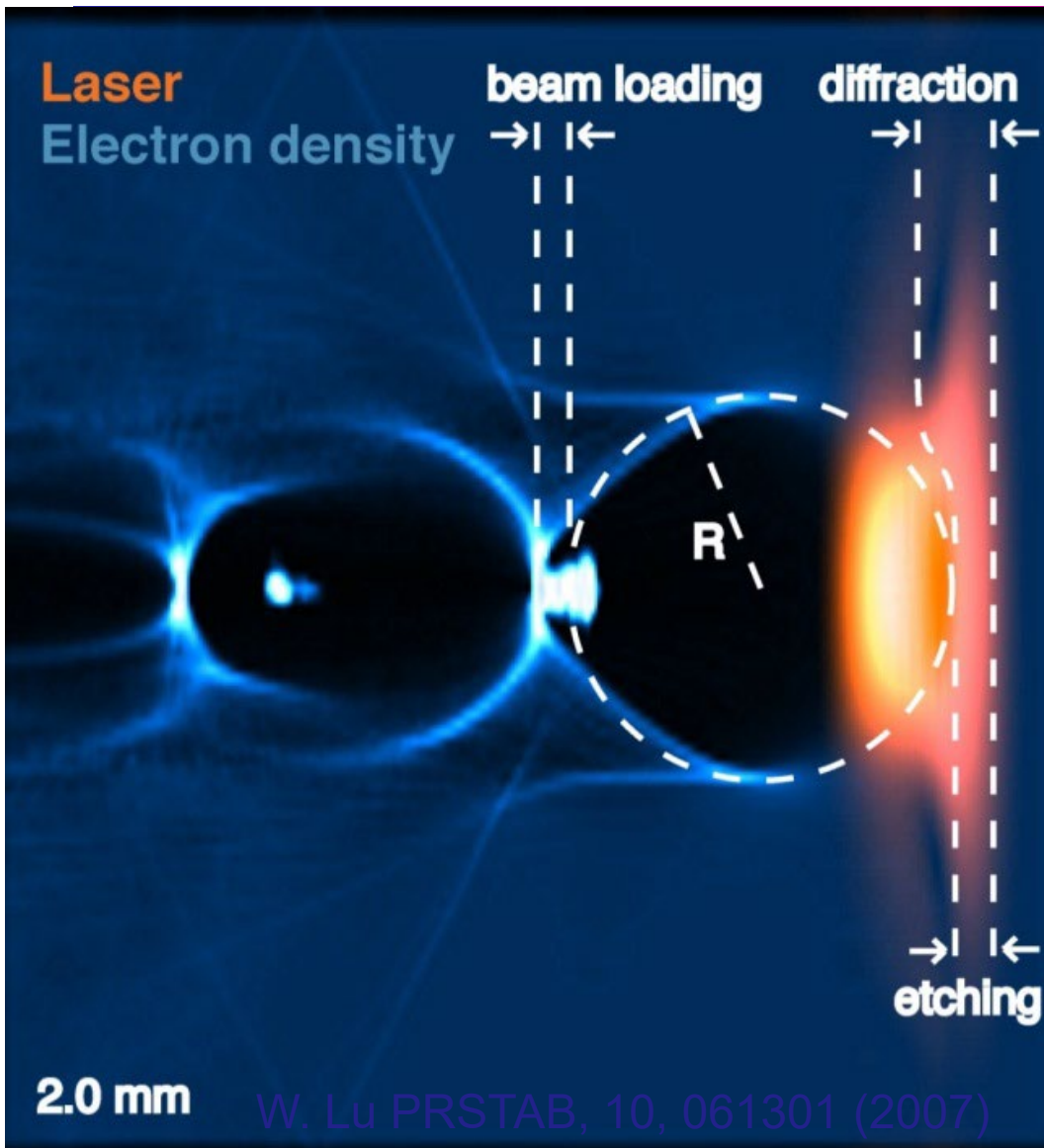
$\omega_p \tau \sim 1$

$a_0 > 2$

Plasma created from background gas distribution (jet, cell, capillary,....)



Self injection of electrons in a plasma cavity is the most simple LWFA-ES



$$a_0 > 2$$

- Pulse compression and self-focussing
- Electrons are expelled from high laser intensity area and leave behind a cavity (bubble filled with ions)
- Electrons self-injected at the back of the bubble and accelerated
- Injected electrons modify the back of the bubble (beam loading)

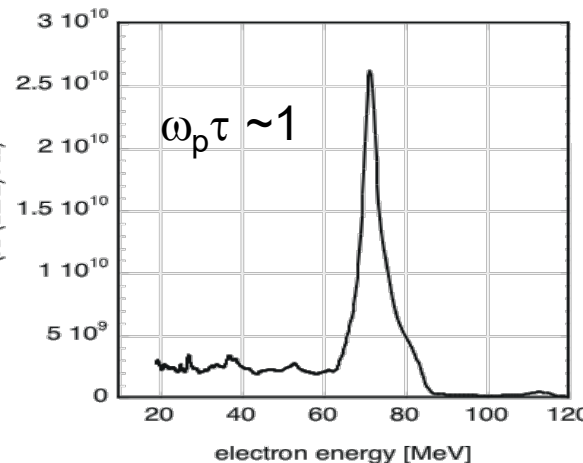
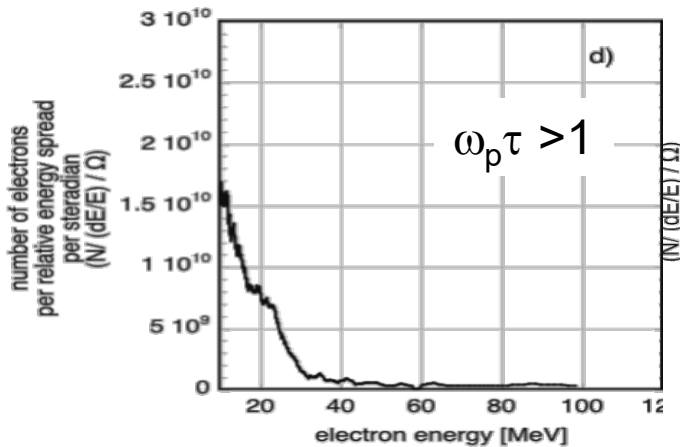
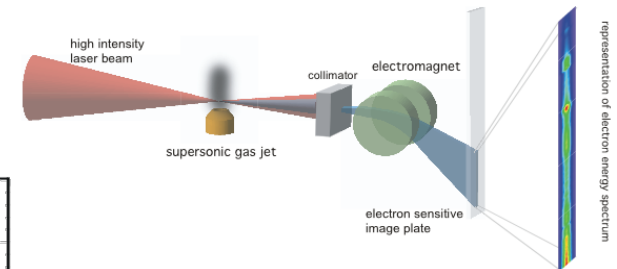


LWFA self-injection with short pulses ($\omega_p \tau \sim 1$) in gas jets



- ➔ Self injection of electrons heated during the interaction of laser pulse and plasma wave,
- ➔ Large energy spread (exponential distribution) due to continuous injection
- ➔ Out of resonance operation: reduced efficiency

- ➔ Typical parameters for operation in **gaz jets** Ti:sapph laser:
- ➔ Electron density $n_e \sim 10^{19} \text{ cm}^{-3}$
- ➔ Pulse duration 40fs
- ➔ Peak intensity $2 \times 10^{18} \text{ W/cm}^2$

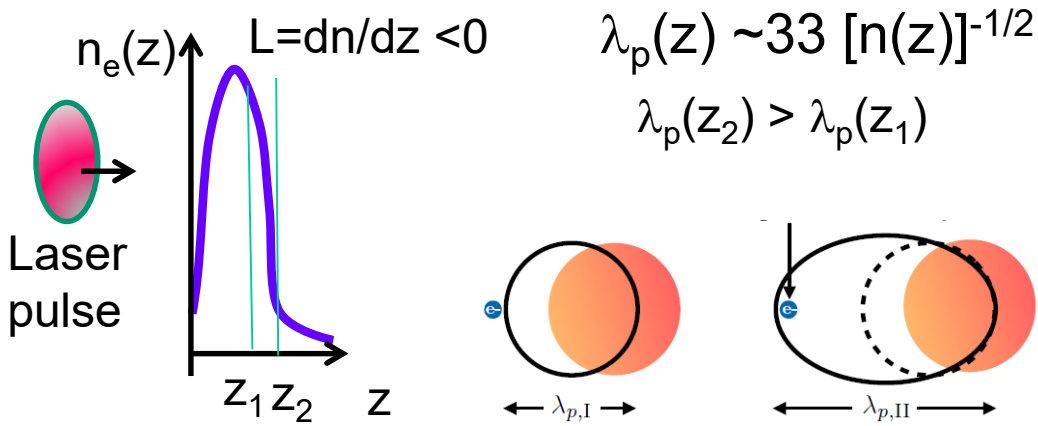




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- ➡ Self-injection mechanism can lead to peaked spectra, with small energy spread (a few %) and small charge (pC)
 - ➡ Other mechanisms can be used leading to more complex plasma designs

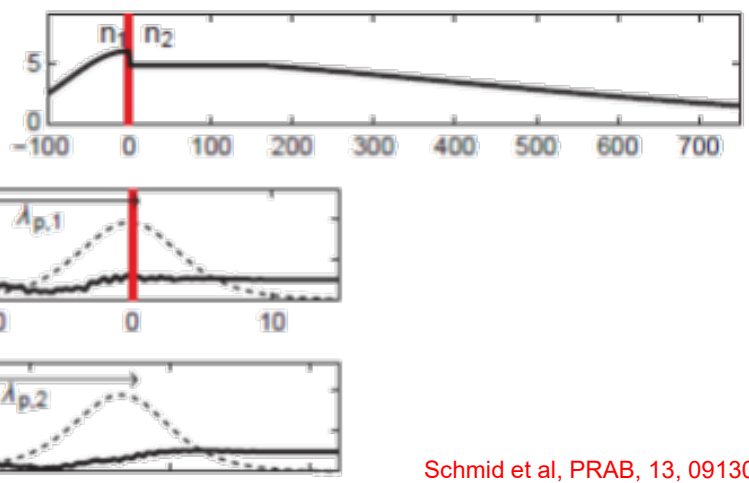


Injection with negative density gradient



the plasma wavelength increases with decreasing density

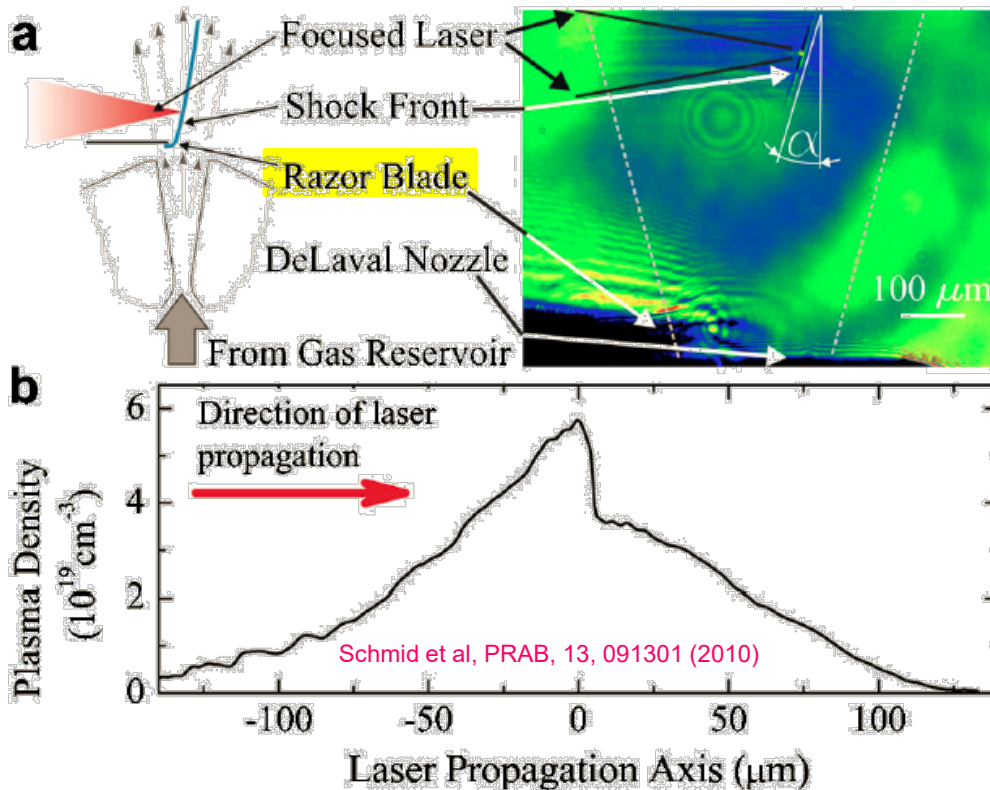
- The back of the wake slows down as the laser propagates down the gradient
- This reduces the trapping threshold
- Trapping can be confined to a small region in the gradient area



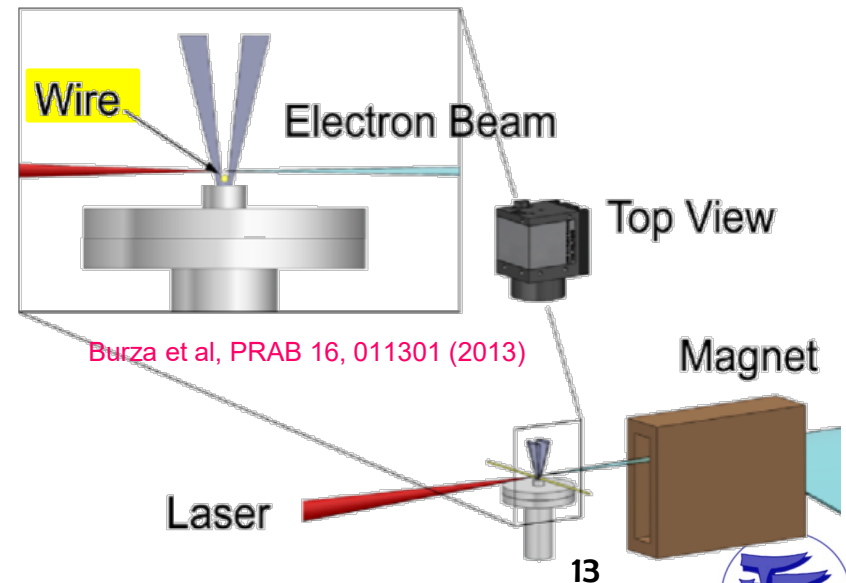
Schmid et al, PRAB, 13, 091301 (2010)



A sudden change in plasma density : practical aspects



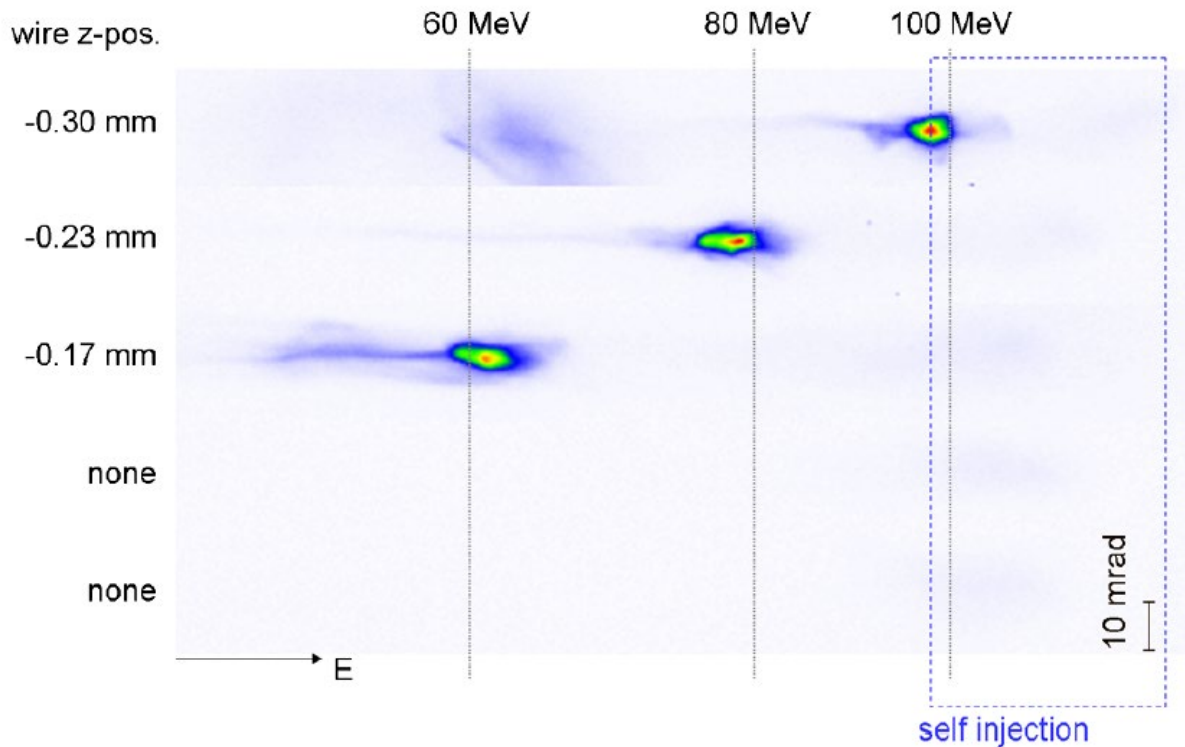
- ➔ An object placed in the gas flow creates a shock associated to change of gas density over a short distance
- ➔ Laser ionisation occurs over a short time scale: the plasma profile follows gas profile



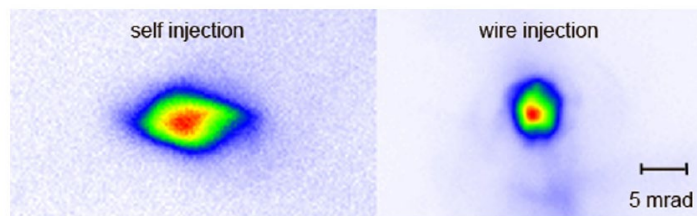
Density gradient injection in gas jet improves beam quality



M. Burza et al. PRSTAB (2013)



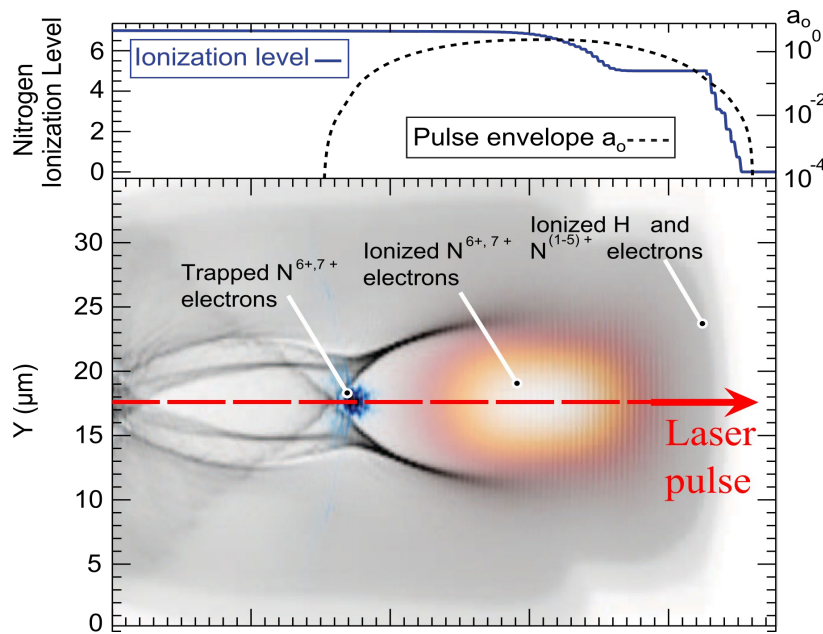
-Density 6 to $3 \cdot 10^{18}$ / cc
Injection can happen at lower background plasma density
- reduces divergence by 25%
Increases charge 10 times compared to SE



- $E = 100$ MeV
- $\frac{\sigma_E}{E} = 4\%$ (fwhm)
- $Q \sim 43$ pC



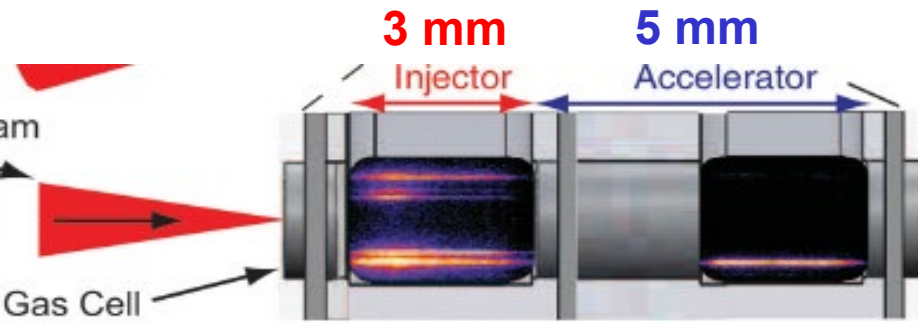
The combination of several mechanisms improves the ES quality



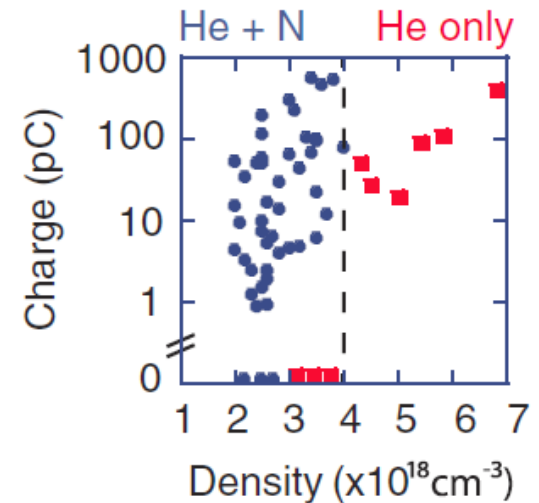
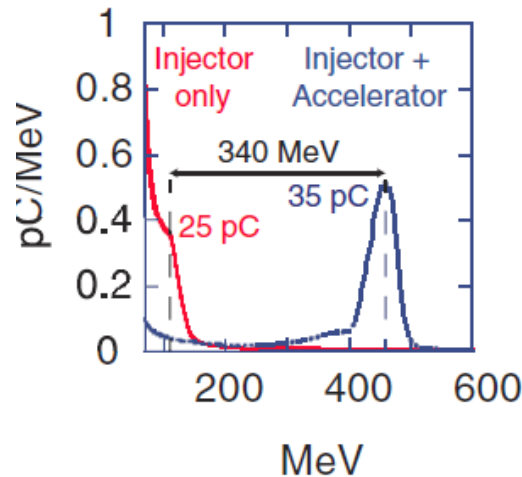
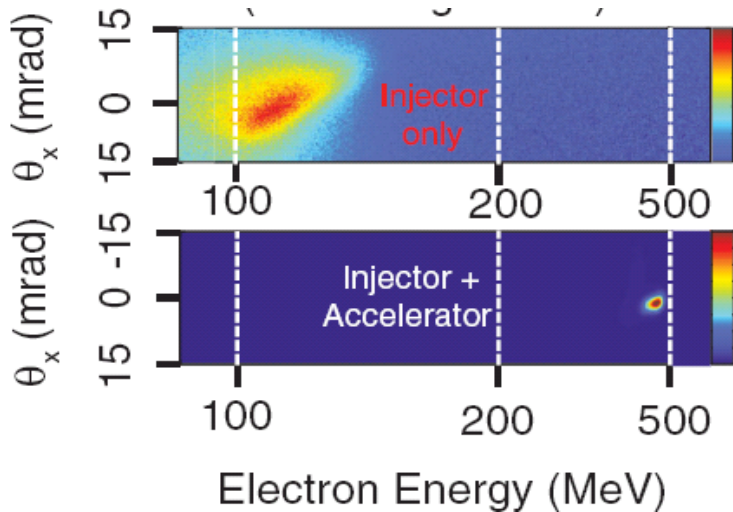
A. Pak *et al.*, PRL – **104**, 025003 (2010)

- ➡ Ionisation induced injection for increased accelerated charge
- ➡ Steep density gradient to stop injection process
- ➡ Use of gas cell for improved flow stability

First test of ionisation injection in a double gas cell



- ➔ Laser 40TW, $n_e = 3 \times 10^{18} \text{ cm}^{-3}$
- ➔ 0.5% Nitrogen in the injector:
- ➔ Lower density accelerator He:
Means longer dephasing length
ie longer acceleration length



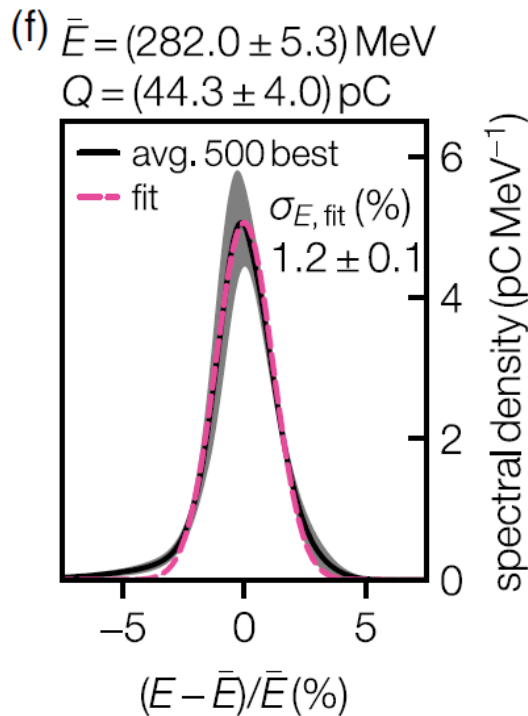
1.4 pC/MeV, Energy Spread FWHM 5%
2.3 mrad divergence



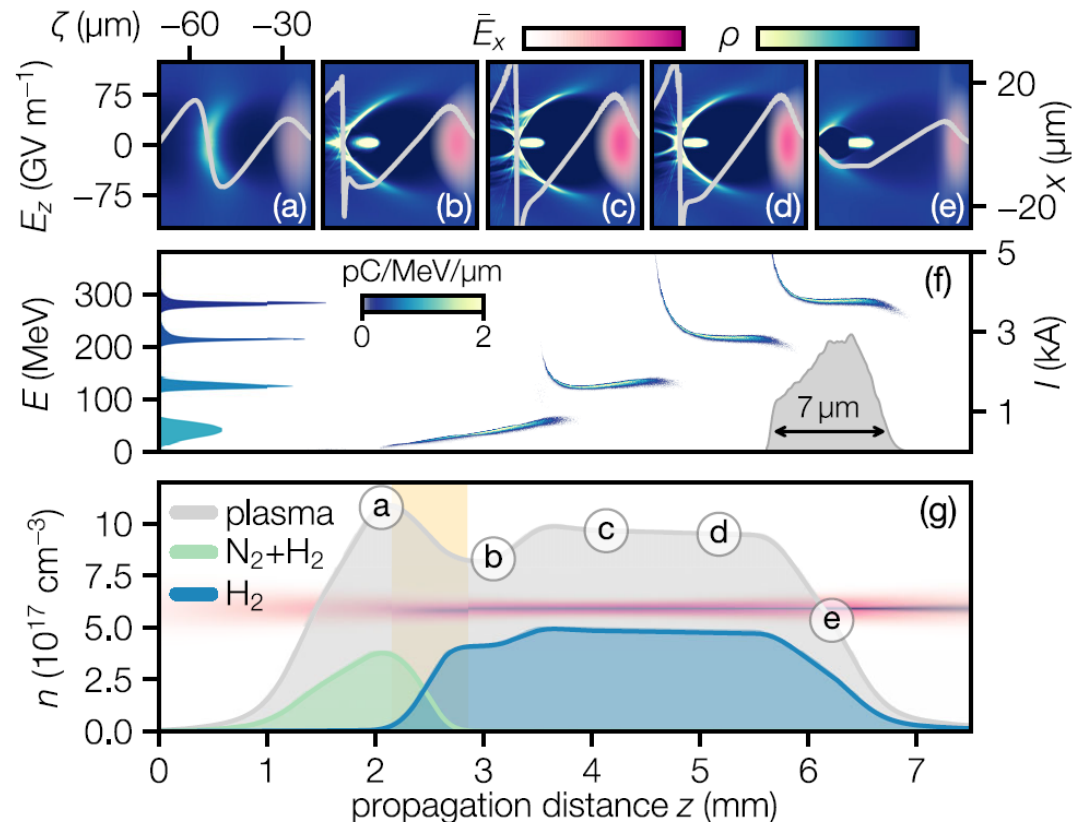
Density tailoring to control injection and acceleration processes



- ➔ Achieved consistently after machine learning optimisation
- ➔ Good agreement with simulations: strong basis for accelerator design



M. Kirchen, PRL 126, 174801 (2021)

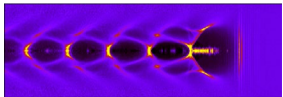


Overview of plasma target capability



Target type	Length mm	n_e value cm^{-3}	n_e tailoring	n_e stability	rep rate	life time
Gas jet	< 20 self-foc.	10^{18}	multiple jets	turbulent flow	10 Hz	> 24 h
Gas cell	> 1 self-foc.	$10^{17} - 10^{19}$	machining	gas feed dependent	10 Hz	laser quality dependent
Plasma channel HE	< 30 guiding	$(1 - 5) \times 10^{18}$ parabolic	similar to gas jet	laser quality dependent	10 Hz	>24h
Plasma channel discharge	10 – 90 guiding	$5 \times 10^{17} - 10^{19}$ parabolic	multiple gas feed	discharge dependent	10 Hz	laser quality dependent
Cap tube	10-1000 guiding	$(0 - 5) \times 10^{17}$ homogeneous	multiple gas feed	gas feed static	10 Hz	laser quality dependent



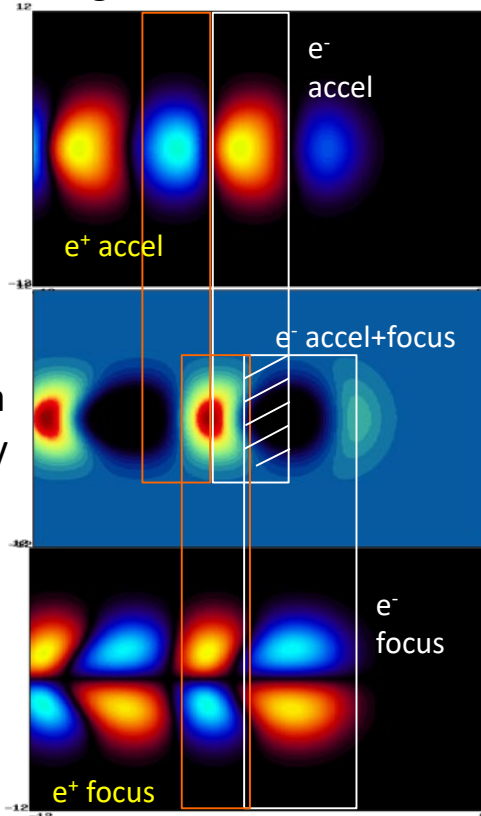


➡ Plasma based accelerator cavity: for laser or beam driven wakefield accelerators

Plasma cavities for accelerator



Accelerating field



- ➔ Quasi-linear regime of acceleration or moderately NL regime to avoid trapping electrons from plasmas (source of noise and perturbation)
- ➔ Acceleration and focussing are achieved within the plasma cavity
- ➔ Plasma cavity can be driven by laser or particle beams
- ➔ Laser driven schemes require some form of guiding (discussed in Howard Milchberg talk)

Focusing field

Source C. Schroeder



Plasma source for particle beam driven wakefield acceleration



- The driver determines plasma characteristics
 - **high-energy driver**, a long plasma is needed, m-scale
 - no guiding need for e^- , uniform transverse density
 - transverse structure for e^+ acceleration: hollow channel, etc (driven by e^- bunch)
 - longitudinal structure for self-modulation (SM)
 - **Low-energy driver**, hybrid LWFA/PWFA : Plasma source uses LWFA solutions



Short electron bunch driver scheme

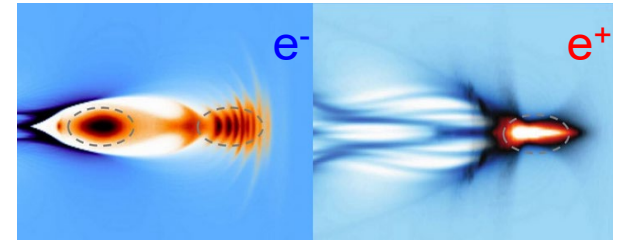


Range of plasma parameters

✧ $k_{pe}\sigma_z \sim k_{pe}\sigma_r \sim 1$ or $\sigma_z \sim \sigma_r \sim c/\omega_{pe}$

✧ Applications may require multiple plasmas (staging),
~100J energy per drive bunch

✧ m-scale plasma (FEL, collider), $n_{e0} \sim 10^{17} \text{cm}^{-3}$, $r_p \gg c/\omega_{pe} \sim 17 \mu\text{m}$



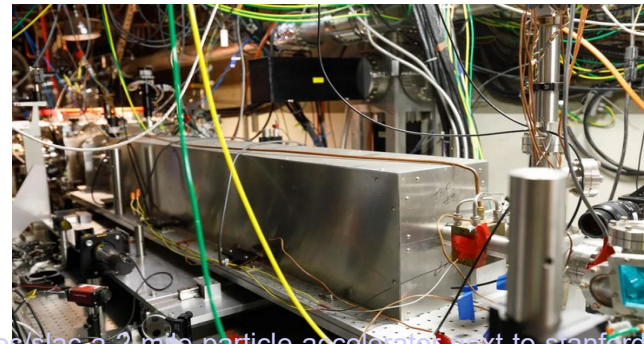
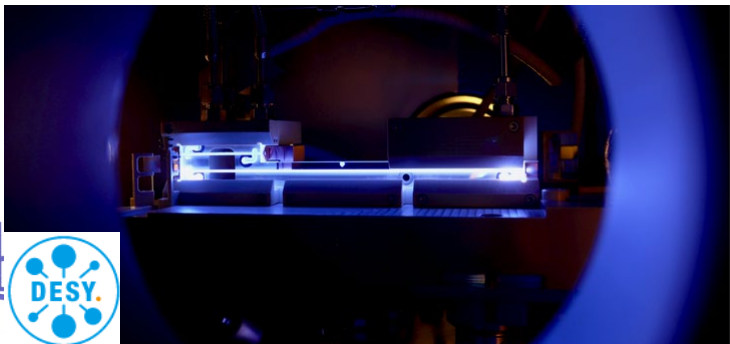
Several options for plasma creation

✧ **Bunch, self-field-ionized** alkali metal vapor \Leftrightarrow limited by head erosion

✧ **Laser-ionized** (alkali metal, hydrogen, etc.) \Leftrightarrow complex \Leftrightarrow limit for staging

✧ **Capillary discharge** \Leftrightarrow walls, pulsed power, repetition

Source P. Muggli



FACET
SLAC



Long p^+ bunch driver scheme



➡ Range of plasma parameters

✧ $\sigma_z \sim 10\text{cm} \gg \sigma_r$, $k_{pe}\sigma_r \sim 1$ or $\sigma_r \sim c/\omega_{pe}$.

✧ Requires self-modulation (SM) for GV/m wakefields amplitude

✧ **10-1000m-scale plasma** (HEP),

✧ $n_{e0} \sim 10^{15}\text{cm}^{-3}$, $r_p \gg c/\omega_{pe} \sim 168\mu\text{m}$

✧ Large energy per bunch: $\sim 10\text{-}100\text{kJ}$

✧ SM requires very good **density uniformity**:

$$\Delta n_e/n_{e0} \ll (\pi/2)(c/\omega_{pe})/\sigma_r \Leftrightarrow \Delta n_e/n_{e0} < 1\%$$



Source P. Muggli

Long p⁺ bunch driver scheme



➡ Several plasma options explored



✧ **Laser-ionized alkali vapor** ⇔ $\Delta n_e/n_{e0} < 1\%$

✧ Limited in length by laser ionization

✧ **Discharge source**

✧ $\Delta n_e/n_{e0}$?

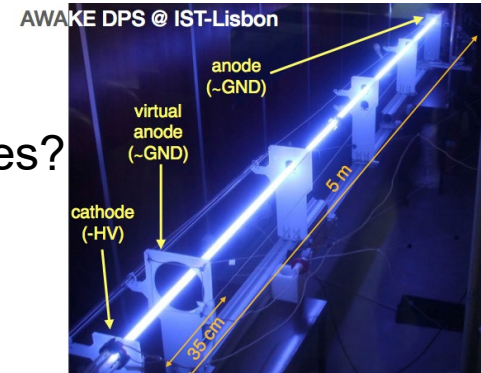
✧ Multiple electrodes/discharges?

✧ **Helicon source**

✧ Modular

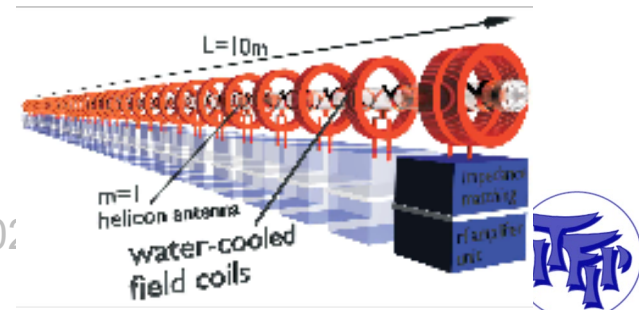
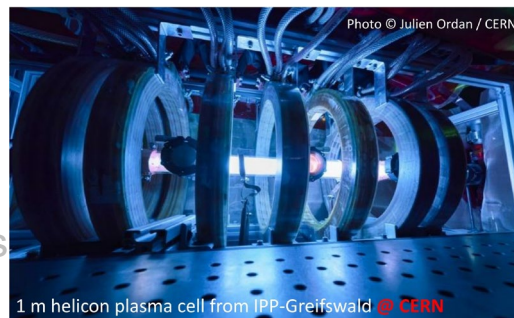
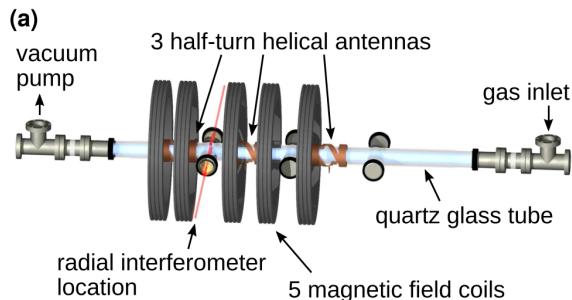
✧ $\Delta n_e/n_{e0}$?

✧ RF-power (~kW/m)



Source P. Muggli

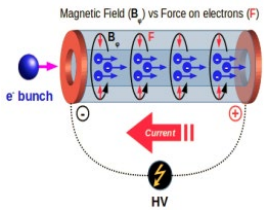
B. Buttenschoen, PFC 60, 075005 (2018).



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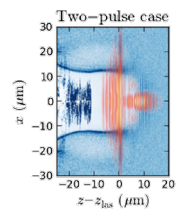
Plasmas for beam optics



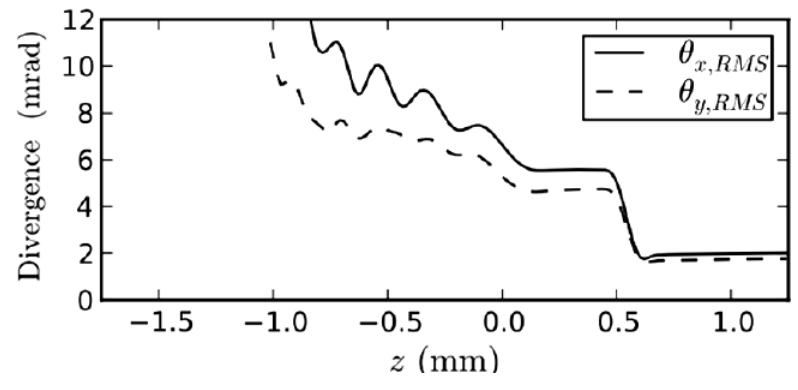
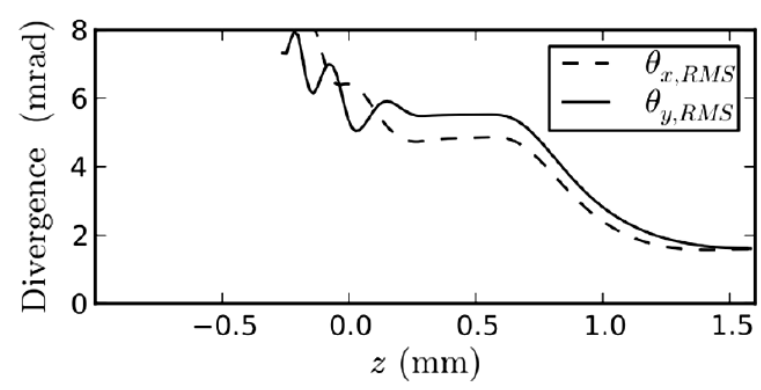
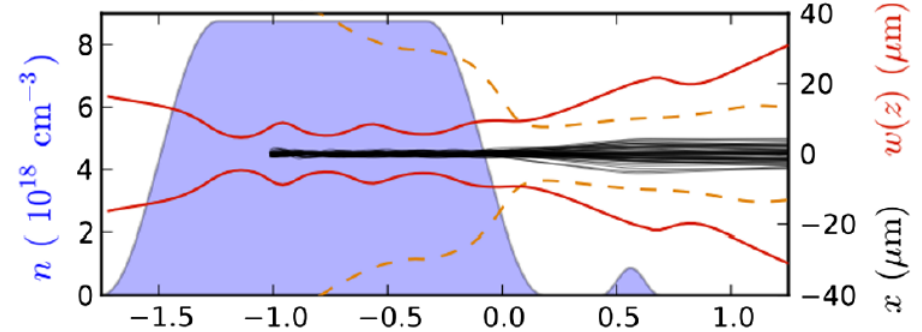
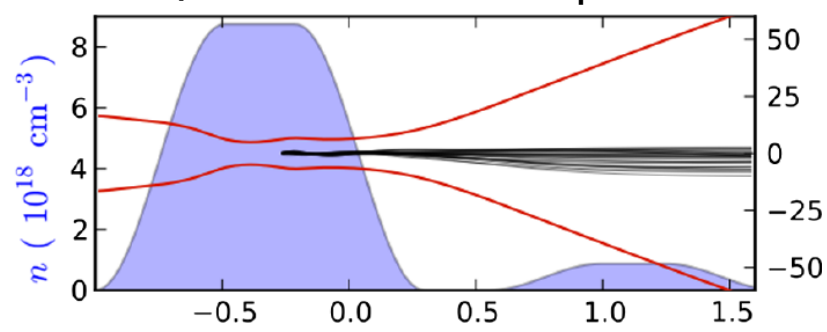
Laser driven plasma lens to reduce divergence of LWFA ES



plasma Drift space plasma



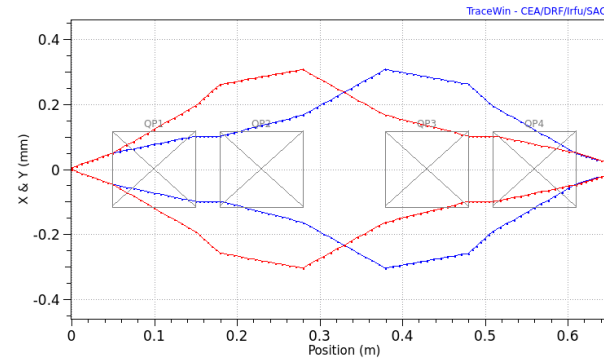
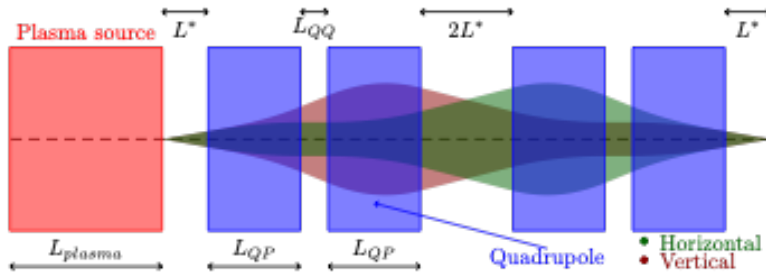
2 pulse case for e beams >200 MeV



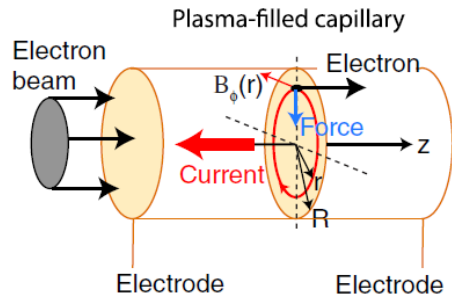
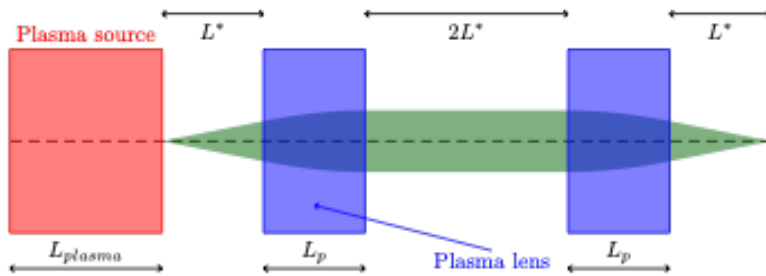
R. Lehe, et al. PRSTAB 17, 121301 (2014)



Magnetic structures: low overhead once aligned, but long distances



Plasma structures: strong focusing gradients

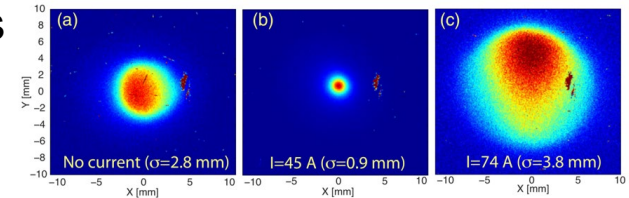


$$n_{\text{beam}} < n_{\text{plasma}}$$

$$n_{\text{plasma}} \sim 10^{18}/\text{cc}$$

Compact: tunable field gradients in excess of 3000 T/m, enabling cm-scale focal lengths for GeV-level beam energies

Radially symmetric focusing of electrons in a plasma lens

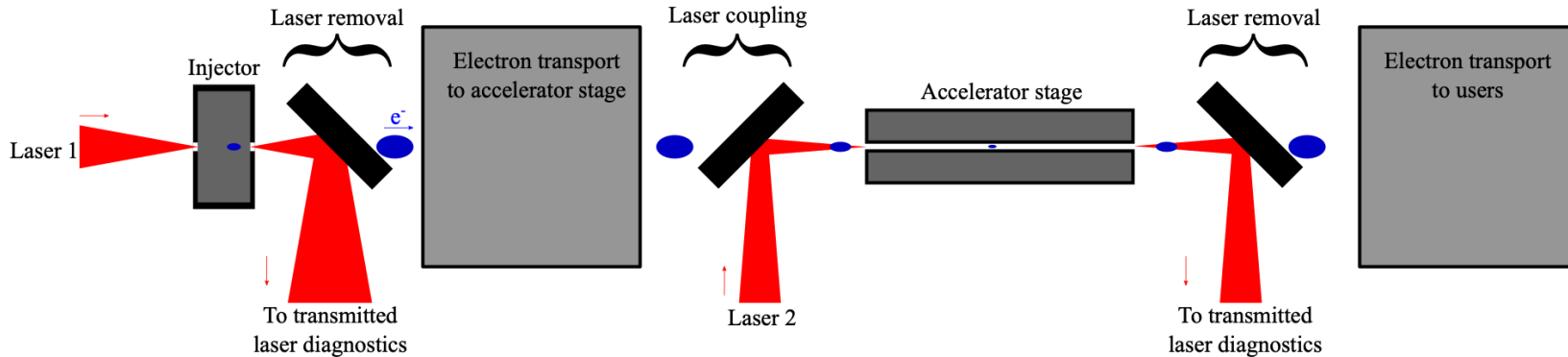


J. Van Tilborg, et al, Phys. Rev. Lett. 115, 184802 (2015).

C. A. Lindström, et al. Phys. Rev. Lett. 121, 194801 (2018)

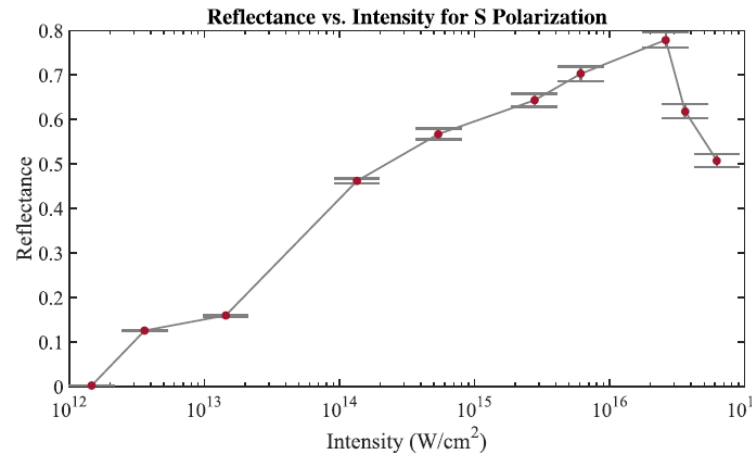
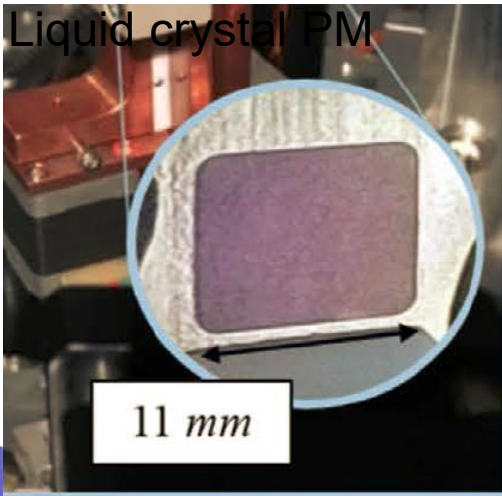


Most investigated option is plasma mirrors:



Tape drives, liquid crystal mirrors

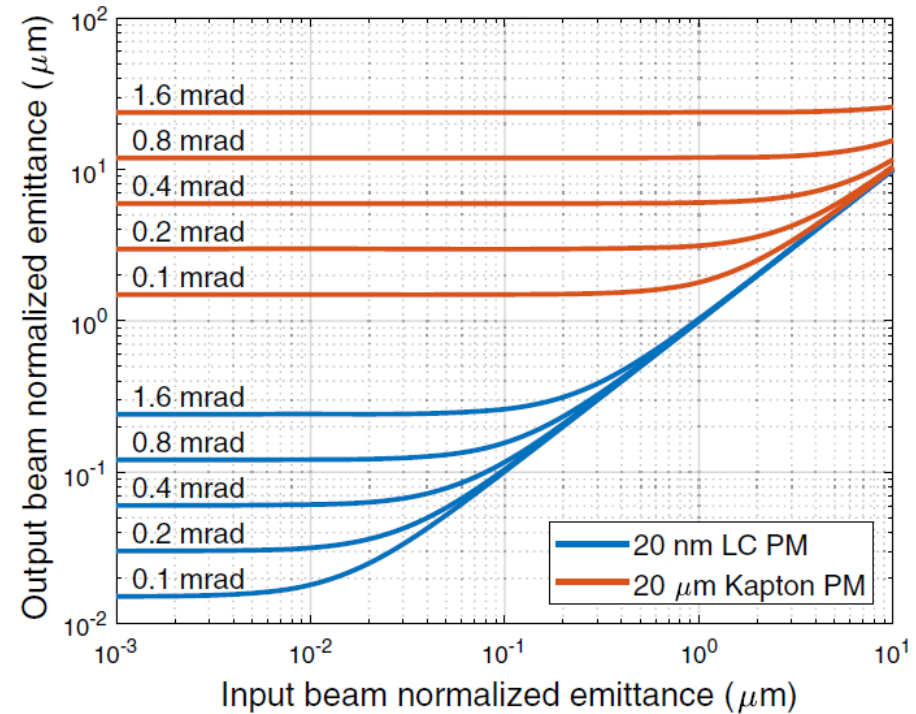
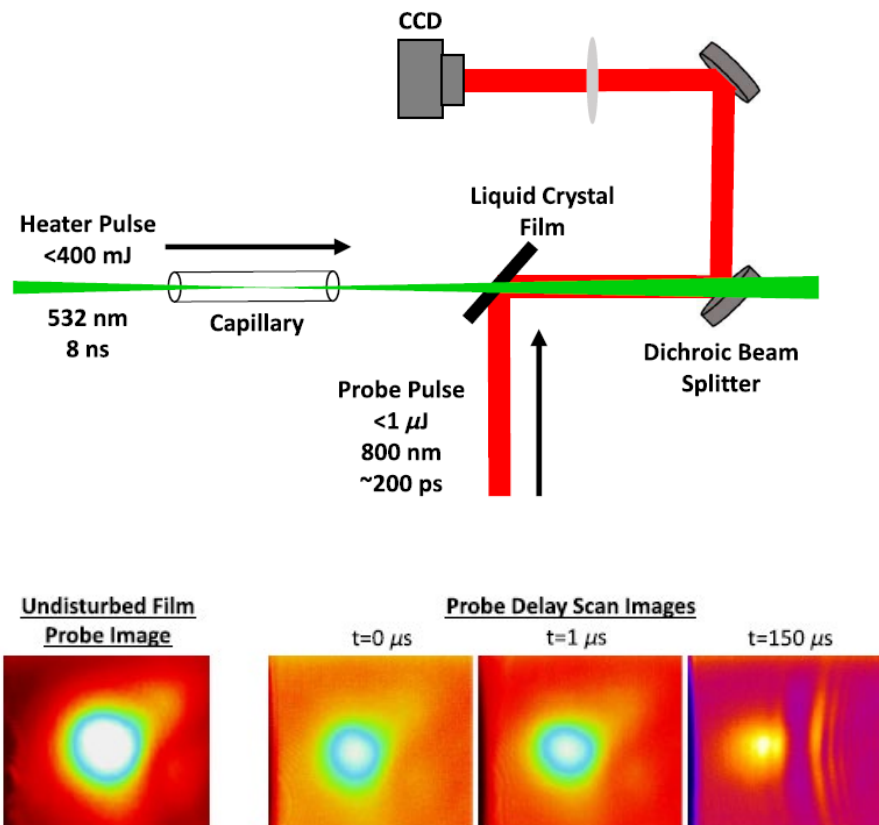
Poole 2016, Scientific Report 6:32041 |



Thin film plasma mirrors for accelerators: tape drive / Liquid crystal



➡ LC 1000 time thinner than TD preserve $1\mu\text{m}$ emittance



Zingale, PRAB, 24, 121301 (2021))

B. Cros, Heraus Seminar, Bad Honnef, May 2022

Summary



- Plasma technology for accelerators comes in several forms for plasma **confinement and tailoring** (jet, cell, capillary, pipes, films)
- Plasma **density** value and distribution are set by the function of each accelerator component, injector, accelerating cavity, laser or beam coupling between stages (10^{15} to 10^{19} or even 10^{21} /cc for mirrors)
- Plasma **stability** (density distribution in space and time) has a strong impact on electron beam properties
- Future developments are expected on **scaling plasma sources** to large sizes, high repetition rate, and on energy management

